

## DEVELOPERS AND REPLENISHERS FOR THERMAL PLATES

DIRECT USE DEVELOPER FOR THERMAL POSITIVE PLATES.

### PROPERTIES

- ▶ Minimum aggression towards coating in the image areas obtaining the maximum cleaning of the non images areas.
- ▶ High emulsion dissolving properties to minimize the accumulation of residues in the automatic processor.
- ▶ Long life in processor.

### APPLICATION

- ▶ Development in processors for thermal plates.
- ▶ Direct use.

### METHOD OF USE

- ▶ Recommended working temperature: 23 °C ± 1 °C.
- ▶ Development time: 30 ± 5 seconds in immersion.
- ▶ Replenishment: Use **DEVELOPER IP-T9** or **REPLENISHER R-T9**.
- ▶ Replenishment rate: 120 ml/m<sup>2</sup>. 50 ml/m<sup>2</sup>.
- ▶ Antioxidant Stand by ON: 100 ml/h. 40 ml/h.
- ▶ Antioxidant Stand by OFF: 100 ml/h. 40 ml/h.

### CONSIDERATIONS

- ▶ Adequate replenishment keeps filters and circulation systems clean prolonging the life of the bath.
- ▶ Correct cleaning of the equipment will avoid contamination of the new bath and prolong the life of the processor.  
Clean using **PROCESSOR CLEANER PC-520** and **PROCESSOR CLEANER PC-600**.

### PACKAGING

- ▶ 20 and 200 liters.
- ▶ Other packaging available on request.

Note:  
The results obtained may vary depending if the conditions of use are outside of our recommended values.